Letters to the Editor

TO A LOW RESISTIVITY STATE IN SEMICONDUCTORS CURRENT INDUCED TRANSITION FROM A HIGH RESISTIVITY

С НИЗКИМ УДЕЛЬНЫМ СОПРОТИВЛЕНИЕМ В ПОЛУПРОВОДНИКАХ С ВЫСОКИМ УДЕЛЬНЫМ СОПРОТИВЛЕНИЕМ В СОСТОЯНИЕ индуцированные током переходы состояния

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In general, the current controlled current-voltage characteristics can be expressed by the relation

$$U=[R_1f(I)+R_2]I.$$

function f(I) must have the following properties: In the case of current induced transition from a high resistivity to a low reistivity state $R_1 \gg R_2$ and the

$$f(I) > 0$$
, $\lim_{t \to 0} f(I) = 0$, $\lim_{t \to \infty} f(I) = 1$, $\frac{df(I)}{dI} < 0$

(2)

Further, if the current-voltage characteristic is of the "S" type, the equation dU/dI = 0, i.e.

$$I\frac{df(I)}{dI} + f(I) + \frac{R_2}{R_1} = 0,$$

(3)

should have two real and positive roots I_n , I_m to which the corresponding voltage U_n , U_m limit the region of negative differential conductivity. The simplest function which fulfils all these conditions is

$$f(I) = \exp(-bI).$$

Then the current-voltage characteristic is given by the relation

 $U = [R_1 \exp(-bI) + R_2]I$

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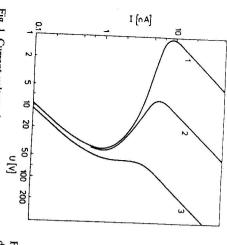
In this case the condition dU/dI = 0 gives the equation

$$(bI-1)\exp(-bI)=R_2/R_1$$

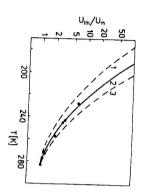
which has two real and positive roots if $R_2/R_1 \le \exp(-2)$.

We note that the formula (6) of Kimata's and Kani's paper [1] (these authors proposed a simple model for the negative resistance taking into account the impact ionization of deep level impurities) can 9

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and $R_1 = 10^6 \Omega$ (1), $10^9 \Omega$ (2), $1.353 \times 10^{10} \Omega$ the formula (5) with $b = 1 \text{ (nA)}^{-1}$, $R_1 = 10^{11} \Omega$, Fig. 1. Current-voltage characteristic described by (3), respectively.



the ratio of experimental values of U_m and U_m tion (8) with $T_0 = 283$ K. and a = 10 (1), 12.6 (2). 15 (3), respectively. The full circles correspond to deces corresponding to R_2/R_1 given by the rela-Fig. 2. The computed U_{th}/U_{m} versus T depenshown in Fig. 3 of the reference [3].

which lead to the formula (5), since this phenomenological formula comprehends the general feature of the transition from high resistivity to low resistivity ohmic regions of the "S"-type current-voltage Arumjunjan [2]. However, we are of the opinion that also other microscopic models can be found be rewritten into the form (5). The model of these authors has been criticized by Avak'yana and

Changing this resistance we get various characteristics, as it is illustrated in Fig. 1. The low resistance state R_2 includes the series resistance of the circuit with the examined sample. The ratio of the threshold to the sustain voltage is given by the formula

$$\frac{U_{m}}{U_{m}} = \frac{\exp(-bI_{m}) + R_{2}/R_{1}}{\exp(-bI_{m}) + R_{2}/R_{1}} \frac{bI_{m}}{bI_{m}}.$$

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ture dependence of R_2 is weaker, then the temperature dependence of the ratio R_2/R_1 can be expressed suppose that the resistance R_1 exponentially decreases with increasing temperature while the tempera-Let us denote the temperature at which $U_m = U_m$ as T_0 . At this temperature $R_2/R_1 = \exp(-2)$. If we

$$R_2/R_1 = \exp\left\{-\frac{a(T_0 - T)}{T} - 2\right\}.$$
 (8)

parameter "a" which fits the experimental data is 12.6, and the experimental value of T_0 is 283 K. Using dependence of U_a/U_m . The results gained with $T_0 = 283$ K, a = 10, 12.6, 15, respectively, are shown in these values we get from (8) that U_{π} on a semiinsulating GaAs(Cr) sample shown in Fig. 3 of our previous paper [3]. The value of the Fig. 2. The full circles in Fig. 2 correspond to the ratio of experimentally determined values of $U_{\scriptscriptstyle M}$ and By numerical solution of Eq. (6) with R_2/R_1 given by the relation (8) with given values of constants T_0 , a, we can find the values of bI_m and bI_m for various T. Then from (7) we get the temperature

$$R_2/R_1 \sim \exp(-3580K/T) = \exp(-0.30 \text{ eV}/k_BT)$$
.

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resistance of the investigated sample can be expressed as GaAs(Cr) base can also lead to the conversion of Cr2+ to Cr1+ ions. We suppose that at low voltage the energy level of about 0.5 eV below the conduction band. The injection of electrons into a semiinsulating donors should allow chromium atoms to capture a second electron, which leads to the Cr1+ state with an Cr2+ ion with the energy level approximately 0.80 eV below the conduction band. Addition of more designed Cr3*. If donors are present, the Cr3+ ion can capture one electron and thus is converted to the number of donors [4, 5]. In the absence of donor impurities chromium atoms are in the state commonly GaAs(Cr) the chromium ions located on gallium lattice sites can be in various states depending on the We suggest the following physical interpretation of this result. It is known that in semiinsulating

$$R_0 = R_1 + R_2$$

where

and

$$R_1 \sim \exp\left(+0.80 \text{ eV/}k_BT\right)$$

 $R_2 \sim \exp(+0.50 \text{ eV/}k_BT)$.

With an increasing current more Cr2+ ions will trap the injected electrons and become Cr1+ ions. Thus

as it follows from the formula (5), and the ratio R_2/R_1 is given by the relation (9). the regions with a resistivity proportional to exp $(+0.80 \text{ eV}/k_BT)$ disappear with an increasing current,

are converted to the state of the lower activation energy. high-resistivity crystalline semiconductors in which, due to the capture of electrons, the impurity-ions Thus we have proposed a new mechanism of the switching effect which can occur in some

the formula (5) if $g_2 \ll g_1$, $E_2 < E_1$, $k_1 < k_2$. respectively. His model leads to the steady current-voltage characteristic which can be approximated by E_2 of the configurations I and II may be elevated due to a current by the amount k_1I and k_2I , each other through an energy barrier $\Delta E=E_1-E_2$ under electric excitation. The energy levels E_1 and I, II with conductivities g_1 and g_2 , which coexist in approximate equilibrium and may transform into films based on the assumption that in amorphous films there are two stable and reversible configurations We note that recently Chiang [6] has proposed the theory of threshold switching in amorphous thin

exponential function of their relation (10). This again confirms that the formula (5) can find a wide relation (5) if we include the series resistance of the circuit and neglect the quadratic term in the model of the switching effect which also leads to the current-voltage characteristic described by the The above mentioned models have an electronic nature. Krempaský et al. [7] proposed a thermal

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